transport through (magnetic) nanoscale objects Herre van der Zant



transport mechanisms: Ohms law $J = \sigma E$

electrons are viewed as particles in a pinball machine, bouncing around resistance results from (back) scattering and can be characterized by the mobility (a material dependent property).



How fast does an electron move in an electric field?

$$\vec{v}_{d} \equiv \left\langle \vec{v}(t) \right\rangle = -\frac{e\vec{E}\,\tau}{m^{*}} \equiv -\mu\vec{E}$$

mobility $\mu \equiv \frac{e \tau}{m^*}$

Drude conductivity

$$\boldsymbol{\sigma} = \frac{\vec{j}}{\vec{E}} = \frac{-en\langle \vec{v} \rangle}{\vec{E}} = ne\mu = \frac{e^2n\tau}{m^*}$$

ballistic transport: 1D channel or a single atom

electrons are viewed as waves that are transmitted in channels; the transmission determines the conductance which is quantized with a value independent on the material



elongation



monoatomic contact



rupture





$$G = \frac{2e^2}{h} \sum_i T_i$$

 T_i : transmission of channel *i*

For one channel and perfect transmission

$$G = \frac{2e^2}{h} = (12.9 \,\mathrm{k}\Omega)^{-1}$$

Which physical quantity determines the number of channels? How fast do the electrons go?

tunneling in one dimension: single-barrier case

gold-vacuum-gold junction: direct, through space tunneling

$$\begin{aligned} x &< -a \quad : \quad u(x) = e^{ikx} + Re^{-ikx} \qquad k^2 = \frac{2mE}{\hbar^2} \\ -a &< x < a : \quad u(x) = Ae^{-\gamma x} + Be^{\gamma x} \qquad \gamma^2 = \frac{2m(V_0 - E)}{\hbar^2}, E < V_0 \\ x &> a \quad : \quad u(x) = Te^{ikx} \qquad k^2 = \frac{2mE}{\hbar^2} \end{aligned}$$

Φ_B = work function
 = 5.3 eV
 (= Fermi-energy gold)

-a

Source

d

 Φ_{P}

Drain

а

 μ_D

X

d = 2a

E

 $\mu_{\rm S}$

tunnel probability :
$$t = TT^* = \frac{1}{1 + \left(\frac{k^2 + \gamma^2}{2k\gamma}\right)^2 \sinh^2(2\gamma a)}$$

strong barrier (2 $\gamma a >> 1$) : $t \approx \left(\frac{2k\gamma}{k^2 + \gamma^2}\right)^2 e^{-4\gamma a} \Rightarrow G = G_0 e^{-4a\sqrt{\frac{2m\Phi_B}{\hbar}}}$

voltage dependence: Simmons' formula for tunneling d = barrier width

 $\Phi_{\rm B}$ = barrier height

$$I = \left(\frac{eA}{4\pi^2\hbar d^2}\right) \left[\left(\Phi_{\rm B} - \frac{eV}{2}\right) e^{-\frac{2d\sqrt{2m}}{\hbar}\sqrt{\Phi_{\rm B}} - \frac{eV}{2}} - \left(\Phi_{\rm B} + \frac{eV}{2}\right) e^{-\frac{2d\sqrt{2m}}{\hbar}\sqrt{\Phi_{\rm B}} + \frac{eV}{2}} \right]$$

expanding the square root ($\Phi_B >> eV$):



J. Simmons, J. Appl. Phys. 34 (1963) 1793

linear response (zero-bias conductance)

$$\sinh(\beta_{\rm v}Vd) \approx \beta_{\rm v}Vd \Longrightarrow G = G_0 e^{-\beta_0 d}$$

gold-vacuum-gold junction

 $\Phi_{\rm B}$ = 5.3 eV m = m₀ = 9.1 10⁻³¹ kg

$$\beta_{\rm V} = \frac{e}{\hbar} \sqrt{\frac{m}{2\Phi_{\rm B}}} = 1.1 \ (\rm{nm})^{-1}$$
$$\beta_{0} = \frac{e\sqrt{2m\Phi_{\rm B}}}{\hbar} = 2.34 \ (\rm{A})^{-1}$$

these are the maximum values when working with gold: in practice lower due to image charges etc.

 β_0 : decay length

an example: breaking of a gold contact



Why is the second step not exactly on 2G₀?



PhD. Thesis Roman Huber

(1,2,3): quantized conductance (G₀) in metallic regime

Landauer formalism: $G=G_0\Sigma T_i$ $G_0=2e^2/h$ (12.9 K Ω or 77mS)

(4): relaxation of the contact

(5): tunneling

$$G\left(d\right) \propto \exp\left(-\frac{\sqrt{8m_e\Phi_m}}{\hbar}d\right)$$

What is the resistance of a single-molecule?

andard I	EIA Color Co	2nd 3rd	Band: ±2%, ±	5%, and ±10
	Band	Band Band	Band	
	2	YYY X		
_	—)	
Color	1st Band	2nd Band	3rd Band	4th Band
	(1st figure)	(2nd figure)	(multiplier)	(tolerance)
Black	0	0	10*	6
Brown		1	101	
Red	2	2	102	±2%
Orange	3	3	102	
Yellow	4	4	104	
Green	5	5	105	
Blue	6	6	108	
Violet	7	7	107	
Grav	8	8	108	6
White	9	9	109	
Gold			10-1	±5%
Silver			10-2	+10%





transmolecular transport: double-barrier problem

The reservoirs (source and drain) are bulk-like regions where the electrons are in equilibrium. These regions are kept at some temperature, and the number of electrons is variable as they are connected to the voltage source. The electrons in these reservoirs are distributed according to Fermi functions.

The molecular island is the part of the system, which is small in all directions– hence, this is the part where the Coulomb interaction (E_c) plays an important role. It is useful to take as a reference the isolated island. In that case we have a set of quantum states with discrete energies (levels, energy Δ).

The molecule-lead coupling is characterized in terms of the rate, Γ , at which electrons cross the tunnel barriers separating the island from the leads. The transport through the barriers is a tunneling process. Γ also sets the life-time of a charge on a molecular state and hence determines the broadening of the level; at present the molecule-lead coupling can still not be controlled and even predicted.

essential for understanding transport:

- Iocation of the levels with respect to the Fermi energy of the electrodes
- the molecule-lead coupling (Γ)



resonant and off-resonant transport

Schematics of the electrochemical potentials of an island connected to two reservoirs, across which a small (negative) bias voltage *V* is applied. A gate voltage is used to shift the electrostatic potential of the energy level.

first order processes





Resonant transport (first-order transport): resonant transport becomes possible when the gate voltage pushes one of the levels within the bias window eV. The $\mu(N)$ level is aligned with μ_s and the number of electrons on the dot alternates between N and N-1 (sequential tunneling).

second order processes





Off-resonant transport: the levels are not aligned. Coulomb blockade fixes the number of electrons on the dot to *N*. Transport, however, is possible through a virtual co-tunnel process in which a unoccupied level is briefly occupied. A similar process exists for the occupied level, $\mu(N)$, which can be briefly unoccupied. In contrast to resonant transport the level is empty (full) most of the time.

off-resonant tunneling through molecular junctions

same exponential distance decay as the single-barrier case but

•
$$\Phi_{\rm B} \Rightarrow {\sf E}_{\sf F}$$
 - ${\sf E}_{\rm LUMO}$ or ${\sf E}_{\sf F}$ – ${\sf E}_{\rm HOMO}$

• m \Rightarrow m^{*}

• $\beta_0 \Rightarrow \alpha \beta_0$ (α takes into account nonrectangular barriers)

 β_0 characterizes electron transfer molecules

alkanes: $\beta_0 \approx 0.9 \text{ Å}^{-1}$ polyenes: $\beta_0 \approx 0.19 \text{ Å}^{-1}$ oligophenyls: $\beta_0 \approx 0.28 \text{ Å}^{-1}$ conjugated molecules: $\beta_0 \approx 0.1$ -0.3 Å⁻¹



the further the molecular level (either the HOMO or the LUMO) is away from Fermi energy of the electrodes (ΔE), the larger the zero-bias resistance

off-resonant tunneling through dithiol-alkanes



exponential length dependence zero-bias resistance



IV characteristics C6 10-7 C8 10⁻⁸ C10 10⁻⁹ Current (A) 10⁻¹⁰ 10⁻¹¹ C8 10⁻¹² C6 C8 C10 C10 A (nm²) 114 56 64 10⁻¹³ s (Å) 8.6 8.8 10.1 ∲ (eV) 1.6 2.1 2.2 -1.5 -1.0 -0.5 0.0 0.5 1.0 1.5 10⁻¹⁴ -1.0 0.0 -1.5 -0.5 0.5 1.0 1.5 Tip Bias (V)

Engelkes, Beebe, Frisbie, JACS 126 (2004) 14287

resonant transport: three-terminal devices



first order processes: sequential tunneling (incoherent)

three-terminal devices:

• levels can be brought in resonance with the leads (if the gate coupling is large enough)!

• molecule can be oxidized or reduced (change its charge state) and the properties of the charged molecules can be studied in detail: this makes it a completely different story !!

chemical potential and addition energy

From non-equilibrium thermodynamics, we know that a current is driven by a chemical potential difference – hence we should compare the chemical potential on the device,

$$\mu(N) = U(N) - U(N-1) = (N - 1/2)\frac{e^2}{C} - eV_{ext} + E_N$$

with that of the source and drain in order to see whether a current is flowing through the device. In experiments, we ground the drain electrode($\mu_D = 0$).







The distance between the two subsequent chemical potential levels, the addition energy (= the energy it costs to put an additional charge on the island) is given by

$$\mu(N+1) - \mu(N) = \frac{e^2}{C} + E_{N+1} - E_N$$

Note that the difference in energy levels occurring in this expression $(E_{N+1} - E_N)$ is nothing but the level splitting.

electronic level structure isolated C₆₀



Energy levels calculated by the density functional method by Green et al., J of Phys. Chem. 100, (1996) 14892.

electronic energies and electrochemical potentials

$$\mu_N \equiv U(N) - U(N-1)$$
 U = total energy

 $\mu_0 = U(C_{60}) - U(C_{60}^{1+}) \approx -7.7 \text{ eV (ionization energy)}$ $\mu_1 = U(C_{60}^{1-}) - U(C_{60}) \approx -2.7 \text{ eV (electron affinity)}$



 $\mu_1 - \mu_0 = \Delta \mathbf{E} + \mathbf{E}_c$

∆E = 1.65 eV

E_c: charging energy (e²/C)

estimate E_c metal sphere: $C = 4\pi\epsilon_0 R$ $R = 0.4 \text{ nm} \Rightarrow E_c = 3.6 \text{ eV}$

analytical solution IV characteristic single-level model



T = 0: f_1 - f_2 = 1 for 0< E <eV and zero otherwise

including spin and for symmetric barriers:

$$I = \frac{2e}{h} \int_{-eV/2}^{eV/2} \frac{\gamma_1 \gamma_2}{(E - \varepsilon)^2 + (\gamma/2)^2} dE$$

$$I = \frac{2e\gamma_1 \gamma_2}{h} \int_{-eV/2-\varepsilon}^{eV/2-\varepsilon} \frac{1}{(E - \varepsilon)^2 + (\gamma/2)^2} d(E - \varepsilon)$$

$$I = \frac{4e}{h} \frac{\gamma_1 \gamma_2}{\gamma_1 + \gamma_2} \left[\arctan\left(2\frac{eV - \varepsilon}{\gamma}\right) - \arctan\left(2\frac{-eV - \varepsilon}{\gamma}\right) \right]$$

current proportional to the broadening γ

current shows steps as resonance crosses bias window



0.0 -2 -1 Voltage (V)

complication: at low bias the model predicts the same dependence as single-barrier tunneling



This can therefore not be used as a proof for molecular transport:



an example: a spin-crossover molecule



T = 6 K mechanically controlled break junction technique

Why is the zero-bias conductance not zero?

Why do the steps not flatten out at high bias voltages?

stability diagram: vary bias and gate voltages



The current is suppressed when all chemical potential levels lie outside of the bias window. As we can tune the location of these levels using the gate voltage. We can calculate the line in the plane which separates a region of suppressed current from a region with finite current. This line is determined by the condition that the chemical potential of the source (or drain) is aligned with that of a level on the island.

For the chemical potential to be aligned to the source $(\mu(N) = \mu_S = -eV)$ and with keeping the dot's charge constant):

$$V = \beta \left(V_G - C V_C / C_G \right)$$

If the chemical potential is aligned with the drain $(\mu(N) = \mu_D = 0)$, we have the linear relation:

$$V = \gamma \left(CV_C \,/\, C_G - V_G \right)$$

See also: J.M. Thijssen and H.S.J. van der Zant, Phys. stat. sol. (b) 245 (2008) 1455-1470.

measured stability diagram carbon nanotubes level splitting and charging energies can be determined



Draw the corresponding chemical potential of the levels and of the energies of the orbitals ...

most experiments thus far: off-resonant transport molecular wires behave as "semiconductors"

Only if clear steps in the current-voltage curves are observed, can we exclude that direct tunneling determines transport.

What about molecular signatures? (addition energies will not work because)

Where to look for molecular signatures:

- Choose for molecules whose (internal) orbital structure does not allow a description in terms of a single tunnel barrier (e.g. quantum interference molecules)

- Perform detailed spectroscopy on the molecules looking for moleculespecific properties (vibrations, spin-related excitations,)

level spectroscopy: excited states (Γ<<U)

incoherent, resonant transport: non-linear regime





- two 'knobs': V_{SD} and V_{gate}
- state contributes to transport if $\mu_s > \mu(N) > \mu_d$

- excited states result in extra lines in stability diagram (red)
- excitations can probe electronic spectrum, spin or vibrational states

excitation lines: electronic fingerprints of molecular vibrations ($\Gamma << U$)







- symmetric with respect to the bias voltage
- excitations the same for different charge states

 more than 15 lines separated by a few meV: unlikely electronic excitations in such a small molecule

E.A. Osorio et al., Adv. Mat. 19 (2007) 281

molecular spin transistor: addressing magnetic properties on a single molecule level using electrons



the molecule: single-molecule magnet Fe₄



easy axis

hard axis

 high stability of Fe₄; retains its magnetic properties when dispersed on a metallic surface (Nat. Mat. 8 (2009) 194; Nature 468 (2010) 417)

• bulk zero-field splitting: ZFS = (2S-1)D = 0.6 meV; energy barrier: U = 1.4 meV

• moderate quantum tunneling (H = $DS_z^2 + E(S_+^2 + S_-^2)/2$); bulk: E= 2 meV

• How to observe anisotropy in an experiment (as Γ in general larger than ZFS)? What are the magnetic parameters for an individual molecule in a solid-state device?

role of the molecule-lead coupling

spacer plus anchoring: tunnel coupling experimentally, the coupling (Γ) can be controlled to some extent; full control requires fixing all atoms positions in the junction



long spacer: weak coupling Delta function DOS

current is blocked to first order involves two (single-particle) charge states



short spacer: intermediate to strong coupling Lorentzian DOS

higher-order tunneling processes (coherent) inelastic spin-flip, Kondo involves only one charge state



higher-order processes in Coulomb blockade

inelastic tunneling spectroscopy (IETS)



Kondo-effect (elastic): spin filling



Kondo: signature of a large quantum spin



A. Zyazin et al., Synth. Metals 161 (2011) 591

inelastic cotunneling: signatures of zero-field splitting



magnetic field dependence: energy splitting increases with B and is symmetric around B=0

